

O I P U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SEPP5.001C1	APPLICATION NO. 10/618,429
INFORMATION DISCLOSURE STATEMENT SEP 10 2003 BY APPLICANT			
(USE SEVERAL SHEETS IF NECESSARY)			
		FILING DATE July 10, 2003	GROUP Unknown

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)	
1	4,058,430	11/15/77	Suntola et al.				
2	6,258,157	07/10/01	Gordon				
3	6,037,003	03/14/00	Gordon et al.				
4	5,922,405	07/13/99	Kim et al.				

FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
5	WO 98/46617	10/22/98	PCT				

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)	
6	6	Drozd et al., "Synthesis of oxide superalloys by ML-ALE method." <u>Applied Surface Science</u> , Vols. 82/83, pp. 587-590 (1994).
7	7	Niinisto et al., "Synthesis of oxide thin films and overlayers by atomic layer epitaxy for advanced application," <u>Materials Science and Engineering</u> , Vol. B41, pp. 23-29 (1996).
8	8	Leskela et al., "ALD precursor chemistry: Evolution and future challenges," <u>J. Phys. IV France</u> , Vol. 9, pp. Pr8-837-Pr8-852 (1999).
9	9	Suntola, "Atomic layer epitaxy," <u>Thin Solid Films</u> , Vol. 216, pp. 84-89 (1992).

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EXAMINER	DATE CONSIDERED
11/12/03	
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.	